



Response  
200312792-1

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

**Inventor:** Chen et al **Confirmation No:** 8388  
**Serial No.:** 10/769,385 **Examiner:** Pamela Schwartz  
**Filed:** Jan 30, 2004 **Group Art Unit:** 1774  
**Title:** Surface Modification Of Silica In An Aqueous Environment

Commissioner for Patents  
P O BOX 1450  
Alexandria VA 22313-1450

### RESPONSE TO RESTRICTION REQUIREMENT

In response to your Office Action/Restriction Requirement dated November 25, 2005; Applicants affirm the election with traverse of Group I (Claims 1-22) Group II (Claims 23-28) and Group III (Claims 29-37 are hereby withdrawn.

Hewlett-Packard Company  
1000 NE Circle Blvd. m/s 422B  
Corvallis, OR 97330  
(541) 715-4197

Respectfully submitted,

Chen et al

By: W. Bradley Haymond  
W. Bradley Haymond, Reg No: 35,186  
Attorney For Applicants

I hereby certify that this correspondence is being deposited on the date indicated below with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, PO Box 1450, Alexandria, VA 22313.

W. Bradley Haymond  
Signature

W. Bradley Haymond  
Typed Name  
12-19-05  
Date of Signature